

RESPONSE UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 2800

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant: Haupt Docket No.: 2003 P 51718 US
Serial No.: 10/766,053 Art Unit: 2822
Filed: January 28, 2004 Examiner: Tran, Thanh Y.
For: Method for N⁺ Doping of Amorphous Silicon and Polysilicon Electrodes
in Deep Trenches

MAY 21 2007

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Submitted
w/ RRP
6/21/07
Paul

RESPONSE UNDER 37 CFR § 1.116

Dear Sir:

Applicant respectfully submits the following amendments and remarks in response to Examiner's Office Action dated March 21, 2007, which Action is made final. Applicant respectfully requests that these amendments and remarks be entered in pursuant to the provisions of 37 CFR § 1.116 in order to place this application in a condition for allowance or alternatively to place the claims in better condition for an appeal, and respectfully request reconsideration of claims 1-27.

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